

Silane, dichloro(chloromethyl)methyl-

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| Other names: | CC3275 CH ₃ SiCl ₂ (CH ₂ Cl) Chloromethyldichloromethylsilane Chloromethylmethyldichlorosilane dichloro(chloromethyl)methylsilane |
| Inchi: | InChI=1S/C2H5Cl3Si/c1-6(4,5)2-3/h2H2,1H3 |
| InchiKey: | JAYBZWYBCUJLNQ-UHFFFAOYSA-N |
| Formula: | C ₂ H ₅ Cl ₃ Si |
| SMILES: | C[Si](Cl)(Cl)CCl |
| Mol. weight [g/mol]: | 163.51 |
| CAS: | 1558-33-4 |

Physical Properties

| Property code | Value | Unit | Source |
|---------------|---------------|------|----------------|
| ie | 10.89 | eV | NIST Webbook |
| log10ws | 0.16 | | Crippen Method |
| logp | 2.314 | | Crippen Method |
| rinpol | 785.80 | | NIST Webbook |
| rinpol | 785.80 | | NIST Webbook |
| tb | 394.50 ± 0.50 | K | NIST Webbook |

Correlations

| Information | Value |
|-----------------------------|-------------------------------|
| Property code | pvap |
| Equation | $\ln(P_{vp}) = A + B/(T + C)$ |
| Coeff. A | 1.12883e+01 |
| Coeff. B | -2.11122e+03 |
| Coeff. C | -7.81250e+01 |
| Temperature range (K), min. | 270.04 |
| Temperature range (K), max. | 431.36 |

Sources

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|---|---|
| Crippen Method: | https://www.chemeo.com/doc/models/crippen_log10ws |
| NIST Webbook: | http://webbook.nist.gov/cgi/cbook.cgi?ID=C1558334&Units=SI |
| The Yaws Handbook of Vapor Pressure: | https://www.sciencedirect.com/book/9780128029992/the-yaws-handbook-of-vapor-pressure |
| Crippen Method: | http://pubs.acs.org/doi/abs/10.1021/ci9903071 |

Legend

| | |
|-----------------|-------------------------------------|
| ie: | Ionization energy |
| log10ws: | Log10 of Water solubility in mol/l |
| logp: | Octanol/Water partition coefficient |
| pvap: | Vapor pressure |
| rinpol: | Non-polar retention indices |
| tb: | Normal Boiling Point Temperature |

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